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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/004,212	11/02/2001	Henry L. Grohman	89746.138901	7799
75	90 03/07/2003			
Ronald S. Karekan, Esq. Jaeckle Fleischmann & Mugel, LLP 39 State Street			EXAMINER	
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Rochester, NY 14614-1310				
			ART UNIT	PAPER NUMBER
			1753	
			DATE MAILED: 03/07/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No. 10/004,212

Applicant(s)

Grohman et al.

Examiner

Rodney McDonald

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The MAILING DATE of this communication appears on the cover sheet with the correspondence address					
Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the					
mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).					
Status					
1) Responsive to communication(s) filed on	· ·				
2a) ☐ This action is FINAL . 2b) ☑ This act	ion is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.					
Disposition of Claims					
-4)-XI- Claim(s)-1-10	is/are-pending-in-the-application. — —				
4a) Of the above, claim(s)	is/are withdrawn from consideration.				
5) Claim(s)	is/are allowed.				
6) 💢 Claim(s) <u>1-10</u>	is/are rejected.				
7) Claim(s)	is/are objected to.				
8)	are subject to restriction and/or election requirement.				
Application Papers					
9) The specification is objected to by the Examiner.					
10) ☐ The drawing(s) filed on is/are a) ☐ accepted or b) ☐ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
11) The proposed drawing correction filed on	is: a) \square approved b) \square disapproved by the Examiner.				
If approved, corrected drawings are required in reply	to this Office action.				
12) The oath or declaration is objected to by the Examiner.					
Priority under 35 U.S.C. §§ 119 and 120					
13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a) All b) Some* c) None of:					
1. Certified copies of the priority documents have been received.					
2. Certified copies of the priority documents have been received in Application No.					
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). *See the attached detailed Office action for a list of the certified copies not received.					
14) ☐ Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).					
a) The translation of the foreign language provisional application has been received.					
15) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.					
Attachment(s)					
1) Notice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper No(s).				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Informal Patent Application (PTO-152)				
3) X Information Disclosure Statement(s) (PTO-1449) Paper No(s). 2 6) Other:					

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DETAILED ACTION

Claim Rejections - 35 USC § 112

1. Claims 3-5 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 3-5 are indefinite because the claimed subject matter should be set forth in writing. It is unclear what the metes and the bounds of claim are.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 1 and 2 are rejected under 35 U.S.C. 102(b) as being anticipated by Hunt et al.

(U.S. Pat. 5,674,367).

Hunt et al. teach that the target blank 10 is fabricated from a material suitable for forming a thin a thin film on a substrate during a sputtering process. This includes materials such as aluminum alloy, gold, silver, copper, platinum, and titanium which are of a purity suitable for the sputtering process. In a preferred embodiment, the target blank 10 is fabricated from titanium. The target blank 10 is substantially disc shaped and includes a horizontal bottom surface 14 and a vertical peripheral wall 16. The mounting ring 12 has a substantially annular shape and includes a

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vertical interior wall 18 for defining a circular aperture 20 which extends through the mounting ring 12. The aperture 20 is sized smaller than the target blank 10 by an amount sufficient for forming an interference fit between the target blank 10 and the aperture 20. In one embodiment, the outer diameter of the target blank 10 is approximately 13.572 inches and the diameter of the aperture 20 is approximately 13.558 inches. Further, the mounting ring 12 includes a cover mounting surface 26 adapted for being mounted to a chamber cover as will be described. In addition, the mounting ring 12 and the target blank 10 each have a first thickness 24. (Column 2 lines 65-68; Column 3 lines 1-18)

Referring to FIGS. 4A-4C, alternate embodiments for the first interface 28 are shown in enlarged views. In particular, each of the embodiments depicted in FIGS. 4A-4C enhance the structural integrity of the target assembly 32. In FIG. 4A, a first alternate embodiment is shown wherein the peripheral wall 16 includes a notch 42 and the interior wall 18 includes a projection 44 which mates with the notch 42, thus capturing the target 38. In FIG. 4B, a second alternate embodiment is shown wherein the interior wall 18 includes the notch 42 and the peripheral wall 16 includes the projection 44, thus capturing the mounting ring 12. Referring to FIG. 4C, a third alternate embodiment is shown wherein at least one pin element 46 extends through the peripheral 16 and interior 18 walls, thus capturing both the target 38 and the mounting ring 12. By way of example, three pin elements spaced 120 degrees relative to each other may be used. (Column 4 lines 8-23)

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4. Claims 1-4 are rejected under 35 U.S.C. 102(b) as being anticipated by Nakamura et al. (Japan 61-067768).

Nakamura et al. teach obtaining a sputtering target enabled to form the film compressed of a uniform composition by providing a target material corresponding to each component of the mixed component of the film in a plane and forming it so that the clearance between each target material is covered and the surface is made at a uniform plane levels. (See Abstract)

In the target which forms the film of MoSi₂ by spattering method, Mo and Si which are the mixed component film are used as a target material to form a target 20 in which the central part 21 comprised of Si and an external peripheral part 23, and an internal circle part 22 comprised of Mo are provided in a triple ring shaped plane. The internal circle part 22 is formed with T-shaped section and tip parts are formed respectively on edges opposed to the central part 21 and the internal part 22 of the external part 23 and fitted to the T-shaped part to cover the clearance and to form these upper surface at the same level. Thus, the generation of erosion of the target is suppressed, the variation of the spattering characteristic is prevented, the forming of the film of uniform component can be made possible and the life is prolonged. (See Abstract)

Figure 1 shows the target attached to a backing plate. (See Figure 1)

5. Claims 1-4, 6 and 7 are rejected under 35 U.S.C. 102(b) as being anticipated by Fukushima et al. (Japan 63-143258).

Fukushima et al. teach that to easily obtain a large-sized target which is free from contamination by pressing plural sheets of thin plate-shaped target elements consisting of Te, Te

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alloy, Se alloy, etc., at side part end faces formed with inclined or curved planes, curved faces, etc., and brazing the same to a cooling plate. (See Abstract)

The large-sized target is obtd. by pressing plural sheets of the thin plate-shaped target elements 1 consisting of Te, Te alloy or Se alloy which is brittle and has no malleability, to each other at the side part end faces 1a, 1a facing each other and joining the same by brazing onto the cooling plate 3. The side part end face 1a of the above-mentioned method is formed to the plane inclined by, for example, about 30° with the cooling plate 3. Sputtering of the constituting components such as the brazing filler metal 2 and cooling plate 3 during sputtering is thereby obviated and the large-sized target which can form the thin films without contamination is easily obtd. at a high yield. (See Abstract)

Claim Rejections - 35 USC § 103

6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was

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made in order for the examiner to consider the applicability of 35 U.S.C. 103© and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

7. Claims 1-4 and 6-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Fukushima et al. (Japan 63-143258) in view of Ivanov et al. (U.S. Pat 5,522,535).

Fukushima et al. is discussed above and all is as applies above. (See Fukushima et al. discussed above)

The differences between Fukushima et al. and the present claims is that Fukushima et al. do not teach replacing the target.

Ivanov teach methods for facilitating recycling of backing plates in bonded target/backing plate assemblies and structural assemblies for use in these methods are disclosed. The target and backing plate are joined by a solder paste material that may be applied to adjoining surfaces of the target and backing plate at low temperature. The paste solidifies to have a high decomposition temperature on the order of greater than 400 °C. Provision of a solder layer having a liquidus temperature of about 100-250 °C between the backing plate and solder paste allows for easy target and backing plate separation and subsequent backing plate reusage. (See Abstract)

The motivation for replacing the target is that it allows for reuse of the backing plate.

(See Abstract)

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have modified Fukushima et al. by replacing the target as taught by Ivanov et al. because it allows for reuse of the backing plate.

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8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Rodney McDonald whose telephone number is 703-308-3807. The examiner can normally be reached on M-Th from 8 to 5:30. The examiner can also be reached on

alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam X. Nguyen, can be reached on (703) 308-3807. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9310.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0661.

RODNEY G. MCDONALD PRIMARY EXAMINER

RM

March 5, 2003